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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/768,515	01/30/2004	Bhanwar Singh	AMDP999US/H1920	6654	
. 23623 AMIN TURO	7590 02/26/2007 CY & CALVIN, LLP		EXAMINER		
1900 EAST 9TH STREET, NATIONAL CITY CENTER			RUGGLES, JOHN S		
24TH FLOOR, CLEVELAND			ART UNIT PAPER NUMBER		
	•		1756		
			MAIL DATE	DELIVERY MODE	
			02/26/2007	PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)	
Advisory Action	10/768,515	SINGH ET AL.	
Before the Filing of an Appeal Brief	Examiner	Art Unit	
•	John Ruggles	1756	
The MAILING DATE of this communication appe	ars on the cover sheet with the c	orrespondence add	lress
THE REPLY FILED 12 February 2007 FAILS TO PLACE THIS	APPLICATION IN CONDITION FO	R ALLOWANCE.	·
1. The reply was filed after a final rejection, but prior to or or this application, applicant must timely file one of the follow places the application in condition for allowance; (2) a Not a Request for Continued Examination (RCE) in compliant time periods:	wing replies: (1) an amendment, aff tice of Appeal (with appeal fee) in c	idavit, or other evider compliance with 37 C	nce, which FR 41.31; or (3)
a) The period for reply expiresmonths from the mailin	g date of the final rejection.	•	
b) The period for reply expires on: (1) the mailing date of this A no event, however, will the statutory period for reply expire I	ater than SIX MONTHS from the mailing	g date of the final rejecti	on.
Examiner Note: If box 1 is checked, check either box (a) or TWO MONTHS OF THE FINAL REJECTION. See MPEP 7		FIRST REPLY WAS F	ILED WITHIN
Extensions of time may be obtained under 37 CFR 1.136(a). The date have been filed is the date for purposes of determining the period of ex under 37 CFR 1.17(a) is calculated from: (1) the expiration date of the set forth in (b) above, if checked. Any reply received by the Office later may reduce any earned patent term adjustment. See 37 CFR 1.704(b) NOTICE OF APPEAL	tension and the corresponding amount shortened statutory period for reply origi r than three months after the mailing da	of the fee. The approprinally set in the final Offi	iate extension fee ce action; or (2) as
2. The Notice of Appeal was filed on A brief in comp	pliance with 37 CFR 41.37 must be	filed within two month	ns of the date of
filing the Notice of Appeal (37 CFR 41.37(a)), or any exte a Notice of Appeal has been filed, any reply must be filed AMENDMENTS			e appeal. Since
3. The proposed amendment(s) filed after a final rejection,			ecause
(a) They raise new issues that would require further co	•	TE below);	
 (b) They raise the issue of new matter (see NOTE beloe) (c) They are not deemed to place the application in beauppeal; and/or 	•	ducing or simplifying	the issues for
(d) They present additional claims without canceling a	corresponding number of finally rej	ected claims.	
NOTE: (See 37 CFR 1.116 and 41.33(a)).			
4. The amendments are not in compliance with 37 CFR 1.1		mpliant Amendment	(PTOL-324).
 5. Applicant's reply has overcome the following rejection(s) 6. Newly proposed or amended claim(s) would be allowed a claim(s) 		timely filed amendme	ent canceling the
non-allowable claim(s). 7. For purposes of appeal, the proposed amendment(s): a) how the new or amended claims would be rejected is pro The status of the claim(s) is (or will be) as follows: Claim(s) allowed: <u>none</u> . Claim(s) objected to: <u>none</u> .		l be entered and an e	explanation of
Claim(s) rejected: <u>1-8</u> . Claim(s) withdrawn from consideration: <u>none</u> .			
AFFIDAVIT OR OTHER EVIDENCE			
8. The affidavit or other evidence filed after a final action, bu because applicant failed to provide a showing of good an was not earlier presented. See 37 CFR 1.116(e).			
9. The affidavit or other evidence filed after the date of filing entered because the affidavit or other evidence failed to a showing a good and sufficient reasons why it is necessar	overcome all rejections under appea	al and/or appellant fai	ls to provide a
10. The affidavit or other evidence is entered. An explanatio REQUEST FOR RECONSIDERATION/OTHER	n of the status of the claims after e	ntry is below or attach	ned.
11. The request for reconsideration has been considered but	t does NOT place the application in	condition for allowar	nce because:

13. Other: _____.

See Continuation Sheet.

12. Note the attached Information Disclosure Statement(s). (PTO/SB/08) Paper No(s).

Continuation of 11. does NOT place the application in condition for allowance because: Applicants' arguments with respect to the prior art rejections under 35 USC 102(b), 103(a) are still not found to be persuasive. First of all, Applicants seem to be confused on pages 8-9 and 11 of the current amendment remarks section about the previous 12/11/06 grounds of rejection over either of the Vasudev et al. references as being in alternative form under 102(b)/103(a) (rather than under 102(b) alone) based on the inherent ability of the vertical sidewall absorbers of the prior art mask structures taught by Vasudev et al. to absorb incident light falling thereon, while adjacent horizontal surfaces of the mask structures are transparent to the incident light. Since these prior art Vasudev et al. masks have substantially the same structure as the instantly claimed mask, they would be expected to inherently function in the same manner as instantly claimed (see MPEP § 2112.01, I. and MPEP § 2114), as previously pointed out. While arguing that Vasudev et al. do not specifically describe the instant intended use of such mask structures having vertical sidewall absorbers, Applicants have failed to show that the Vasudev et al. mask structures are not capable of performing in the manner described by the previous 12/11/06 Office action on pages 6-8. In fact, the Vasudev et al. prior art vertical sidewall absorbers would be considered effective for blocking light from any direction or any angle, but these prior art sidewall absorbers would be especially effective for blocking incident vertical light due to the apparent greater thickness in the vertical direction than in the horizontal direction of these prior art sidewall absorbers. Secondly, Applicants rely on the limitation "for a nonoprint lithographic process" at the top of page 9 in the current amendment remarks section, but this limitation is not even specifically recited by the instant claims. Thirdly, Applicants' further arguments on pages 11-13 concerning other instant claims rely on those previously addressed above.

Nevertheless, the current amendment to cancel previously withdrawn claims 9-23 is entered and the current specification amendments are also entered. Therefore, the previous objection to Figure 8 is now withdrawn in view of the current specification amendment at page 10 line 1 of "882" to --852--.

While the previous specified objections to the abstract labeled (A)-(C) are withdrawn in view of the current amended abstract, this amended abstract prompts new objections as follows: (a) at lines 1-2, "to facilitate the reproduction small features" should be changed to --to facilitate [[the]] reproduction OF small features-- and (b) at line 8, "features, that allow" should be changed to --features, [[that]] WHICH allow--, in which text in all CAPITAL letters indicates addition.

The previously exemplified objections to the specification numbered (1)-(3) are also withdrawn in view of the current entered specification amendments.

However, the specification is still objected to as currently amended, because of Applicants' failure to use proper idiomatic English, misspellings, etc. (see MPEP 608.01 for a description of specification requirements). Further examples of remaining reasons for objection to the specification as currently amended include the following: (4) at page 2 line 10, "reduction in size form the mask to the projected image" is confusing and should be changed to --reduction in size [[form]] FROM the mask to the projected image--; (5) at page 2 line 30, "patterns are place on the mask" should be changed to --patterns are placeD on the mask--; and (6) at page 5 line 8, "though" is misspelled and should be corrected to --thRough--, if these changes better represent Applicants' original intention for the meanings of these passages. Applicants' assistance is also requested in correcting all other errors of which they are aware.

jsr 571-272-1390

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